In place of PTO-1449 U. S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE SEP 1 0 2004 Complete if Known Form Application Number 10/816,730 Filling Date April 2, 2004 INFORMATION DISCLOSURE Applicant(s) Chun-Chieh Lin STATEMENT BY APPLICANT Art Unit 2818 (use as many sheets as necessary) To Be Determined Examiner Name 24061.188 (TSMC2003-1374) SHEET OF Attorney Docket Number

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